Photoluminescence studies of cubic GaN epilayers


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The luminescence properties of cubic GaN films grown upon 3C-SiC/Si (001) substrates by MOCVD were investigated. The spectra show luminescence peaks which are associated with donor bound exciton recombination and donor acceptor pair recombination. A reduced peak energy for the D0X emission compared values reported in the literature suggests a tensile-strain-reduced bandgap of approximately 3.27 eV, which is consistent with the absorption edge in photoluminescence-excitation spectroscopy. The presence of hexagonal material introduces a broad emission band at 3.40 eV with a FWHM of 190 meV, extending to energies up to 3.60 eV. The intensity of this emission scales linearly with excitation power, its peak energy and width remaining unchanged. This band is associated with an absorption edge below 3.70 eV and therefore is not caused by absorption into phase-pure cubic or hexagonal GaN. The photoluminescence lifetimes measured across this band reduce from 0.40 ns to 0.20 ns with increasing emission energy. All these observations can be explained by considering a type-II-band alignment adjacent to stacking faults within the cubic GaN.

1 Introduction InGaN/GaN quantum wells (QWs) grown on cubic GaN are not subject to the strong electric fields perpendicular to the plane of the wells found in conventional QWs grown along the c-axis of hexagonal GaN [1–3]. So, compared with c-plane hexagonal structures, the electron-hole wavefunction overlap is increased, which should lead to an increase in the radiative recombination rate. In addition, since cubic GaN has a smaller bandgap than hexagonal GaN, longer wavelength visible QW emission can be achieved with a comparatively lower indium content. This will reduce the lattice mismatch at the heterointerface and may therefore lead to reduced defect densities in QWs. These two effects are likely to improve the internal quantum efficiency (IQE) of cubic InGaN/GaN QWs, and make them promising active layer candidates for efficient green LEDs [4,5]. However, cubic GaN is thermodynamically metastable during growth; therefore often a large proportion of the stable hexagonal phase will form in the structure which can negatively impact the structural and luminescence properties of the films [6]. Therefore, detailed study and optimisation of cubic GaN is an important step towards device development.

3C-SiC/Si (001) substrates have a number of favorable properties which make them well-suited for the epitaxial growth of cubic GaN [1,6–14]. These substrates can be produced with large diameters and are therefore compatible with commercial processing in Si foundries, providing a clear path to commercialisation of cubic GaN based LEDs. Also, the relatively small lattice mismatch between 3C-SiC and cubic GaN (3.7% [15]) has the potential to reduce the strain in the crystal and improve the crystal quality compared with other substrates.
Here we investigate the effect of hexagonal phase impurities on the photoluminescence (PL) spectra of cubic GaN grown on 3C-SiC/Si substrates.

2 Experimental Method The cubic GaN studied in this work was epitaxially grown via metal-organic chemical vapour deposition (MOCVD) using a two-step growth method similar to that described by Wei et al [6]. The growth was performed on ca. 1x1 inch$^2$ pieces cut from 100 mm diameter 3C-SiC/Si (001) substrates. A reference sample (A) was produced upon a substrate with 750 µm of Si (001) and 7.0 µm of 3C-SiC, and consisted of a layer of 250 nm of cubic GaN. X-ray diffraction (XRD) reciprocal space maps reveal a relatively low integrated intensity for the 1011 hexagonal GaN reflection compared with the symmetric 002 cubic GaN reflection, indicating that the amount of hexagonal material is around 5%. Sample (B) was produced on a 6.3 µm layer of 3C-SiC on a 525 µm thick Si (001) layer, which contained a 250 nm cubic GaN layer, followed by a 10 nm AlN interlayer, and a 500 nm layer of GaN above this. A significantly higher amount of hexagonal GaN in sample (B), around 50%, was observed in XRD measurements. The phase impurities can also be observed in TEM measurements, such as those shown in Figure 1, which indicate the presence of hexagonal GaN above the interlayer in sample B. This is incorporated as crystal inclusions up to 300 nm in size and thin planes of hexagonal GaN known as stacking faults (SFs). A 5.0 µm layer of c-plane hexagonal GaN grown upon c-plane sapphire was also studied for comparison, (C).

These samples were mounted upon the cold-finger of a closed-cycle helium cryostat at temperatures between 10 K and 300 K. Excitation was performed using a CW 40 mW HeCd laser emitting at 325 nm (3.81 eV), focussed to provide excitation densities up to 4000 Wcm$^{-2}$. The 1/e absorption depth of this excitation is approximately 80 nm [12,18] and the 1/e carrier diffusion length at low temperature is expected to be of a similar magnitude [19]. The number of photoexcited carriers which recombine close to the interfaces with the interlayer or substrate is therefore expected to be small; these measurements are most sensitive to the material near the surface of each sample. A comparison of samples A and B would therefore reflect the difference between cubic and mixed-phase GaN. The luminescence was collected by a double-grating spectrometer with 24 Å resolution and detected with a PMT using lock-in amplification techniques. The emission spectra from such a setup is typically influenced by Fabry-Pérot interference, which was reduced by orienting the samples at Brewster’s angle, with the unreflected p-polarised light selected by a linear polariser and collected by the spectrometer [20].

Photoluminescence-excitation spectroscopy was performed on samples using a 300 W Xe lamp, combined with a monochromator, to provide a variable-energy excitation source. In this technique, the excitation photon energy is varied whilst monitoring the luminescence intensity at a constant photon energy.

To measure the PL time-decays of the samples, a frequency tripled Ti:sapphire laser was used to produce excitation pulses with a 100 fs duration at a wavelength of 267 nm. Standard time-correlated single-photon counting techniques were used to produce a histogram of the variation of photon counts versus time delay for various detection energies, with a time-resolution of 0.08 ns.

3 Results and Discussion The PL spectra of all samples measured at 10 K are shown in Figure 2. The bandgap of unstrained hexagonal GaN at these temperatures is 3.50 eV [21]. Sample C exhibits an intense excitonic peak (X) at 3.48 eV, with a full-width at half maximum (FWHM) of 12 meV, which is followed by two LO phonon replicas, each separated by 91 meV. Broad emission bands are present at 3.00 eV and 2.20 eV, each with a FWHM around 400 meV, which are the yellow and blue luminescence (YL, BL) bands commonly reported in the literature [22].

In contrast, cubic samples A and B show dominant emission peaks at 3.23 eV and 3.24 eV respectively. Photoluminescence-excitation measurements in Figure 3 indicate that the emission is associated with a steep absorption edge between 3.26 eV and 3.27 eV.
dependent PL measurements show the peak energy initially blueshifts up to 120 K, before redshifting at higher temperatures, as shown for sample B in Figure 4. The peak energy follows a Varshni bandgap temperature dependence above 120 K, with parameters $\alpha = 0.538(8) \text{ meVK}^{-1}$ and $\beta = 300(100) \text{ K}$, which are within the expected range for GaN [21]. This temperature dependence allows us to attribute this feature to recombination of excitons bound to neutral donors (D$^0$X) within the cubic GaN at low temperature. As the temperature is increased, the bound excitons are ionised, resulting in recombination of free excitons, causing the resultant blueshift [9]. The assignment is also consistent with the observed PL decay curves, as in Figure 5, which shows that the decay transients of the feature are fast (0.17 ns lifetime) and monoexponential [23] for the first 70% of the decay. An additional, slower monoexponential component with 0.65 ns lifetime is present in these decay curves, which may be caused by spectral overlap with the wing of the high energy band seen in Figure 2 for sample B, which will be discussed later.

It is of note that the peak energy of the D$^0$X features are lower than reported in the literature by between 3.10 eV and 0.04 eV [7,9,11,12,23–28]. This may be a result of a reduced bandgap due to tensile strain in the GaN [23], which lies between $0.5 \times 10^{-3}$ and $3 \times 10^{-3}$ for sample A.

Figure 2 Normalised PL at 10 K for all samples, measured with an excitation power density of 10 Wcm$^{-2}$. Inset is the same spectra on a semi-log scale to illustrate the blue luminescence and phonon replicas in sample C.

Figure 3 PL spectrum of sample B measured at 10 K with an excitation energy of 3.81 eV (solid line), 10 K photoluminescence-excitation spectra (dot and dash lines), with detection energies of 3.40, 3.18, 3.12 and 2.85 eV, indicated by arrows, which correspond to the high energy band, between the DAP and D$^0$X peaks, the DAP peak and the low intensity band respectively. The increase in photoluminescence-excitation intensity close to the detection energy is caused by the scattered excitation beam.

Figure 4 Temperature dependence of the peak energy of the near-band-edge emission for sample B (black). An empirical Varshni fit to measurements above 140 K is shown (red) and extrapolated to 10 K.

Figure 5 PL time decays for sample B, measured at 10 K. The discontinuity in decays at 1.40 ns is caused by the system response.
at room temperature, as revealed by high resolution XRD measurements of multiple on- and off-axis reflections. The unstrained bandgap of cubic GaN is 3.30 eV at 10 K [21]; therefore the bandgap of these samples is reduced to between 3.26 eV and 3.27 eV, which corresponds well with the absorption edge in the photoluminescence-excitation spectra. In sample B, the D\(^{3}X\) peak energy is 10 meV higher than sample A, which could be caused by a reduction in tensile strain towards the top of sample B.

The second peak in the spectra in Figure 2, centered at 3.15 eV and 3.13 eV for samples A and B also correspond to an absorption edge in Figure 3 at the cubic GaN bandgap, but are not present in the PL spectra above 80 K. As the excitation power is increased, the peak intensity increases sublinearly and blueshifts by 0.04 eV, as shown in Figure 6. The decay transients for this emission are not mono-exponential, as shown in Fig. 5, and faster decays are observed at higher energies, as in Figure 7. These behaviours are indicative of donor-acceptor recombination (DAP) [24].

The DAP peak energy at 10 W cm\(^{-2}\) is 0.02 eV higher in sample A than B in Figure 2. If this is corrected for the relative bandgaps of the two samples the difference is increased to 0.03 eV. In addition, the intensity of the DAP peak relative to the D\(^{3}X\) is also reduced in sample B. This is tentatively ascribed to a reduced density of the associated donor and/or acceptor states.

Both samples A and B present a low intensity emission band centered at 2.00 eV in Figure 2, with FWHM of approximately 400 meV. This is tentatively assigned to the YL, based on data reported previously for hexagonal GaN [22]. The YL is less dominant in sample A, which suggests there may be a reduced density of carbon and oxygen impurities and gallium vacancies to which the YL is typically attributed [29, 30].

Figure 6 Power dependence of the peak energies for the DAP emission (black) and high energy band (blue) in the PL spectra of sample B in Figure 2.

Figure 7 1/e lifetimes (blue) of PL decays, such as those in Figure 5, at 10 K. The 10 K PL spectrum (black) for sample B, measured under pulsed excitation. The circled point is the lifetime of the low intensity background of the D\(^{3}X\) decay.

An additional low intensity band is present near 3.00 eV in sample A and B. Photoluminescence-excitation measurements in Figure 3 show an absorption edge around 3.27 eV, which suggests that this emission is associated with the cubic GaN. This emission is typically attributed to various DAP and free-to-bound recombination pathways and phonon replicas in cubic GaN with unknown origins [12, 23–25] and is comparable in intensity between samples A and B.

A conventional assessment of the crystal quality is given by the FWHM of the D\(^{3}X\) peak and the \(\omega\)-broadening of the 002 X-ray reflection, which in these samples, reduces from 47 meV and 38’ in sample A to 33 meV and 30’ in sample B respectively. This suggests that the local quality of regions of cubic material is improved for sample B. However, this corresponds with the introduction of an emission band, with a peak emission energy of 3.40 eV and a FWHM of 190 meV, in the PL spectrum of sample B. Since this feature is not present in sample A, it is reasonable to conclude that it is a result of introducing the AlN interlayer into the crystal.

Defect luminescence within the AlN interlayer can be ruled out as the cause of this emission band since the layer is only 10 thick, and the excitation energy is below the bandgap energy of the AlN (6 eV). Luminescence in this region of the spectrum has previously been attributed to hexagonal GaN [8, 9, 11, 12, 23], although significant emission above the recombination energy of excitons in hexagonal GaN has not been reported. It is therefore likely that the hexagonal GaN, as either inclusions or stacking faults in the TEM, is responsible for the emission band.

The photoluminescence-excitation spectra for the 3.40 eV band are in Figure 3, which show a shallow absorption edge starting between 3.60 eV and 3.70 eV. This
is not consistent with the bandgap of hexagonal GaN. In addition, the onset of the absorption edge shifts by approximately 0.05 eV when detecting at different energies across the emission band. The emission extends to energies as low as 3.18 eV, which is evident as a comparable absorption edge is observed in the photoluminescence-excitation spectrum measured at this energy. This behaviour suggests that the emission does not originate from the hexagonal inclusions seen in the TEM, for which we might expect a narrower peak, similar to the exciton from sample C in Figure 2. This could be due to exciton diffusion out of the inclusions, since the diffusion length in GaN has been measured to be similar to the size of the inclusions [19].

As the excitation density is increased, the intensity of this band increases linearly and the peak energy is unchanged, as shown in Figure 6. The FWHM is also independent of the excitation density. There is therefore no indication of any saturation effects. Furthermore, PL time decay measurements in Figure 5 indicate that the decay transients are monoexponential and fast, with lifetimes around 0.20 ns at the highest emission energies. At reduced energies, the lifetime increases, reaching 0.40 ns at 3.30 eV in Figure 7. At further reduced energies, the lifetime reduces since the D\textsuperscript{9}X becomes the dominant component in the spectrum. However, there remains a lower intensity, longer lifetime monoexponential component to the decay. The lifetime of this component can be found via a biexponential fit to the decay, yielding 0.68 ns. This is assigned to the high energy band, since the lifetime of this decay is consistent with the approximately linear trend for the other decays in this band.

Adjacent to SFs, a type-II QW-like potential profile is formed [31–34], as shown in Figure 8. Electric fields are present due to differences in the spontaneous polarisation fields of the two crystal phases [21]. Recombination will occur with electrons, confined within the cubic GaN by the electric fields and SF barriers, and holes, confined in a triangular QW by the electric fields. More densely packed stacking faults will result in a narrower confinement region for the electrons, which will increase the confinement energy and hence the recombination energy. It is clear from Figure 8 that this could occur above 3.50 eV, the hexagonal GaN bandgap, and may therefore account for the PL in Figure 2. The absorption edge would occur due to a reduction in the density of states as the energy falls below $E_{\text{Abs}}$, as indicated in Figure 8. This energy is a few 100 meV larger than the bandgap of hexagonal GaN and may explain the absorption edge energies in Figure 3. This band alignment spatially separates the carriers and would result in a PL decay time that reduces as the recombination energy increases, consistent with observations in Figure 7. Therefore this densely packed SF picture can qualitatively account for the observations of the high energy band.

4 Summary Two samples of GaN grown by MOCVD upon 3C-SiC/Si (001) substrates were studied to investigate the luminescence properties of a cubic and a mixed phase layer of GaN, samples A and B respectively. These properties were compared with a c-plane hexagonal GaN-on-Sapphire sample, sample C. Photoluminescence-excitation measurements at 10 K illustrated that the majority of emission features below 3.27 eV were associated with cubic GaN. Temperature and power dependent PL measurements, along with PL time decays, were used to identify the origins of the main PL features: a dominant D\textsuperscript{9}X peak between 3.23 eV and 3.24 eV, followed by a DAP peak between 3.15 eV and 3.13 eV and the YL at 2.00 eV. A comparison of the peak D\textsuperscript{9}X energy and absorption edge between these samples and literature lead to an estimated strain-induced cubic GaN bandgap between 3.26 eV and 3.27 eV.

The DAP emission for sample B is less intense than that in sample A and the peak energy is lower for equivalent excitation powers, which we tentatively attribute to a lower density of donor and/or acceptor impurity states in this sample. In contrast, the YL is more intense in sample B.

The PL spectra indicate that sample B has a reduced D\textsuperscript{9}X FWHM compared to sample A and a 0.01 eV larger bandgap. This suggests that the local tensile strain of the cubic material has been partially relaxed. An emission band with a peak energy at 3.40 eV and a FWHM of 190 meV is also observed for sample B. This emission band extends to energies up to 3.60 eV, above the hexagonal GaN bandgap.
measurements show a shallow absorption edge below approximately 3.70 eV, which indicates this cannot be due to absorption in phase-pure cubic or hexagonal GaN. The PL decays for this emission are monoexponential and fast, with lifetimes around 0.30 ns, decreasing at higher energies. This may be a result of quantum confinement at bunches of stacking faults.

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